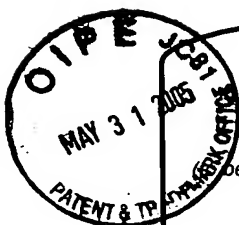


JPW

Please type a plus sign (+) inside this box → +



TRANSMITTAL FORM

to be used for all correspondence after initial filing)

Application Number	10/632,825
Filing Date	August 4, 2003
Inventor(s)	Yun-Jung LEE et al.
Group Art Unit	2826
Examiner Name	Evan T. Pert
Attorney Docket Number	9862-000016/US

ENCLOSURES (check all that apply)

☐ Fee Transmittal Form

☐ Fee Attached

☒ Amendment

☐ After Final

☐ Affidavits/declaration(s)

☐ Extension of Time Request

☐ Express Abandonment Request

☐ Information Disclosure Statement

☐ Certified Copy of Priority Document(s)

☐ Response to Missing Parts/
Incomplete Application

☐ Response to Missing
Parts under 37 CFR
1.52 or 1.53

☐ Assignment Papers
(for an Application)

☐ Letter to the Official Draftsperson and
____ Sheets of Formal Drawing(s)

☐ Licensing-related Papers

☐ Petition

☐ Petition to Convert to a
Provisional Application

☐ Power of Attorney, Revocation
Change of Correspondence Address

☐ Terminal Disclaimer

☐ Request for Refund

☐ CD, Number of CD(s) _____

☐ After Allowance Communication to
Group

☐ LETTER SUBMITTING APPEAL
BRIEF AND APPEAL BRIEF (w/clean
version of pending claims)

☐ Appeal Communication to Group
(Notice of Appeal, Brief, Reply Brief)

☐ Proprietary Information

☐ Status Letter

☒ Other Enclosure(s)
(please identify below):

**Replacement Drawings - Figs.
8A-8E**

Remarks

SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT

Firm
or
Individual name

Harness, Dickey & Pierce, P.L.C.

Attorney Name

John A. Castellano

Reg. No.

35,094

Signature

Date

May 31, 2005



PATENT
9862-000016/US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS: Yun-Jung LEE et al. CONF. NO.: 9195
SERIAL NO.: 10/632,825 GROUP: 2826
FILED: August 4, 2003 EXAMINER: Evan T. Pert
FOR: METHOD OF FORMING OXIDE LAYER USING ATOMIC
LAYER DEPOSITION METHOD AND METHOD OF
FORMING CAPACITOR OF SEMICONDUCTOR DEVICE
USING THE SAME

AMENDMENT

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop Amendment

DUE: May 28, 2005

Dear Sir:

Responsive to the Official Action dated February 28, 2005, the following amendments and remarks are respectfully submitted in connection with the above-referenced application.

Amendments to the specification begin on page 2 of this paper.

Amendments to the claims begin on page 3 of this paper.

Amendments to the drawings begin on page 12 of this paper.

Remarks begin on page 13 of this paper.